ASMMC.9CP1DV1C1 PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE.

Applicant : Sherman

Appl. No. : 10/683,727

Filed: October 10, 2003

For : SEQUENTIAL CHEMICAL

VAPOR DEPOSITION

Examiner : Kelly M. Stouffer

Group Art Unit : 1762

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

The present paper is submitted in response to the Office Action mailed on October 31, 2006. Applicant respectfully requests consideration of the subsequent remarks.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Remarks/Arguments begin on page 4 of this paper.